

TOWARDS PEROVSKITE LIGHT EMITTING DIODE (PeLED) DISPLAY

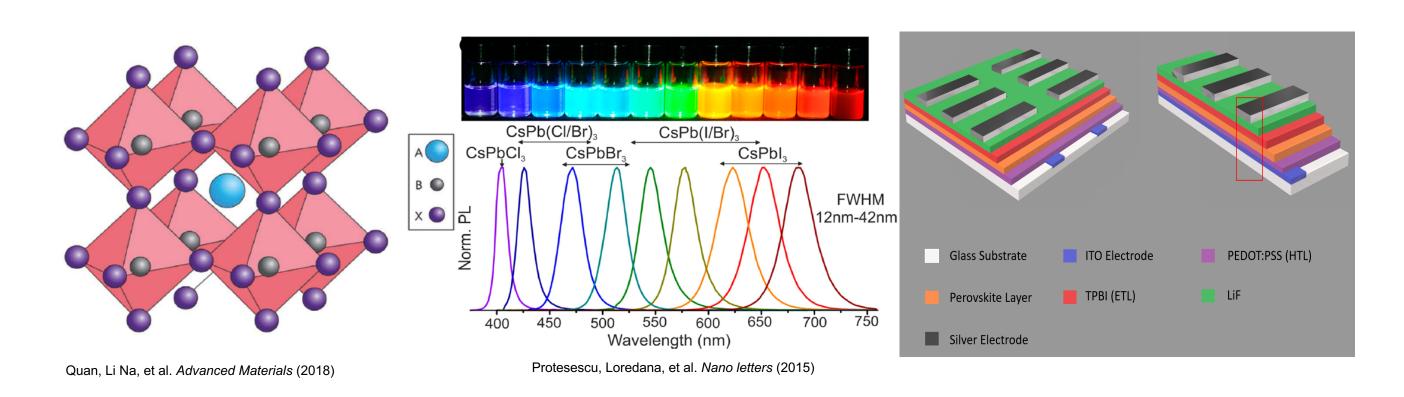
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Introduction

- Perovskite is named after Russian mineralogist Lev Perovski. It was first referred to a calcium titanium oxide mineral, CaTiO3, and later applied to the class of compounds with a similar crystal structure, ABX₃.
- Perovskite materials are highly promising solution-processable semiconductors for next-generation light-emitting applications.
- However, perovskites dissolve in most polar solvents, like water and lithographic developers, which makes perovskites not compatible with widely-used photolithographic processes which are necessary for device fabrications.
- Here we present a high-resolution, large-scale photolithographic method to pattern multicolor perovskite films, and work towards perovskite LED displays.

PeLED

- Perovskites show great potential as light-emitting materials because they have high photoluminescence efficiency, high color purity, high tolerance for defects, tunable bandgaps and low fabrication costs.
- Perovskite LEDs can be easily fabricated by spin coating and evaporation. The simple device structures and fabrication processes make it possible to integrate perovskite light source on silicon-based chips.
- A typical perovskite LED contains electrode, hole transporting layer (HTL), emission layer (EML), and electron transporting layer (ETL).



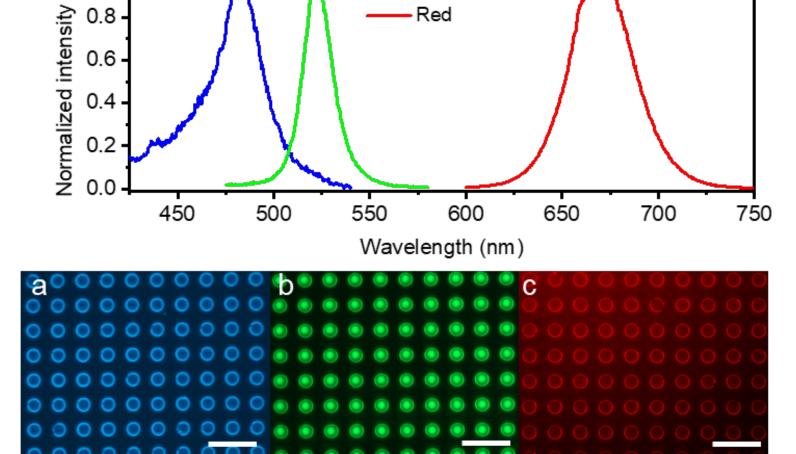
Patterned perovskite

- Perovskite materials are ionic, which makes them tend to be dissolved in common polar solvents that are often used in high-resolution lithographic methods.
- Possible solutions are: utilizing orthogonal lithography and sacrificial layers, dry etching, inject printing, and template-assisted growth.
- However, besides polar solvent, high heat, UV exposure and moisture during the patterning process will also affect perovskites performance.
- In our work, a dry patterning process is developed and applied.

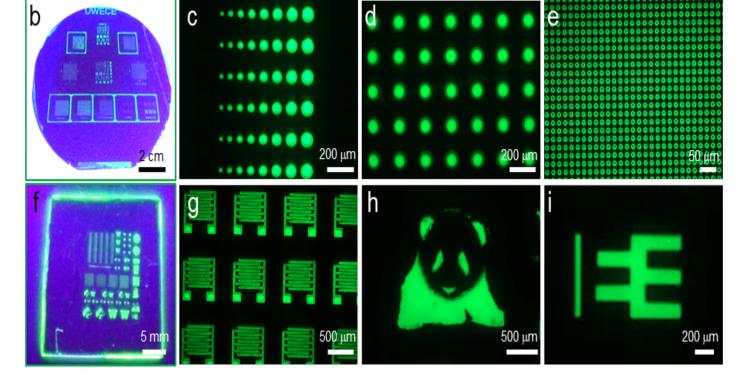
2. Pattern intermediary layer 4. Develop 1. Deposit intermediary layer by photolithography developer intermediary layer intermediary layer intermediary layer Glass Substrate **Glass Substrate** Glass Substrate Glass Substrate 7. Lift-off intermediary layer 8. Patterned perovskites 5. Etch 6. Spin coat perovskite Glass Substrate Glass Substrate **Glass Substrate**

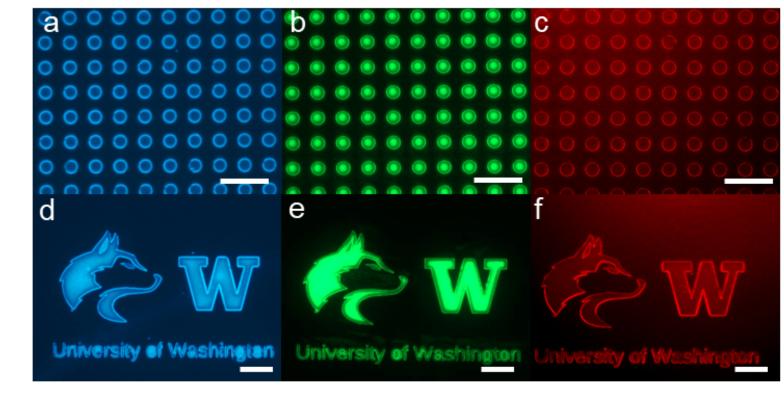
Single color perovskite patterns

- The bandgap of perovskite materials can be easily tuned by changing their chemical composition.
- Perovskites with different colors can be patterned by the same method.



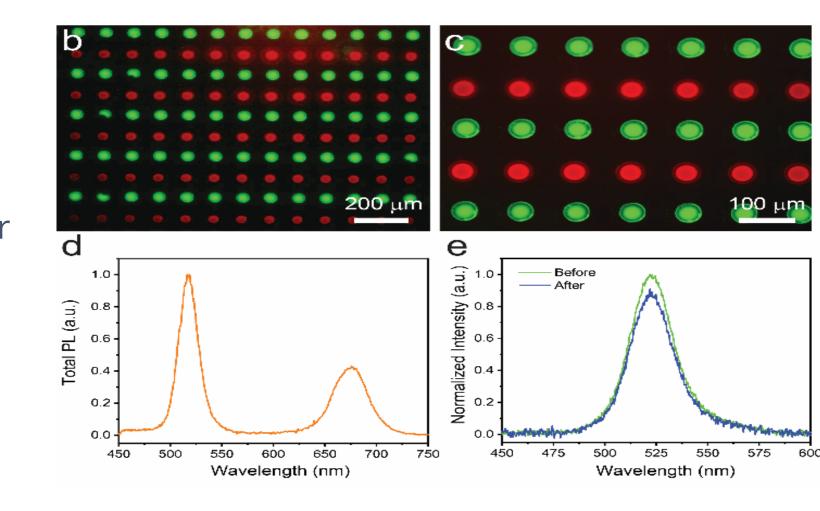
----- Green





Multi-color perovskite patterns

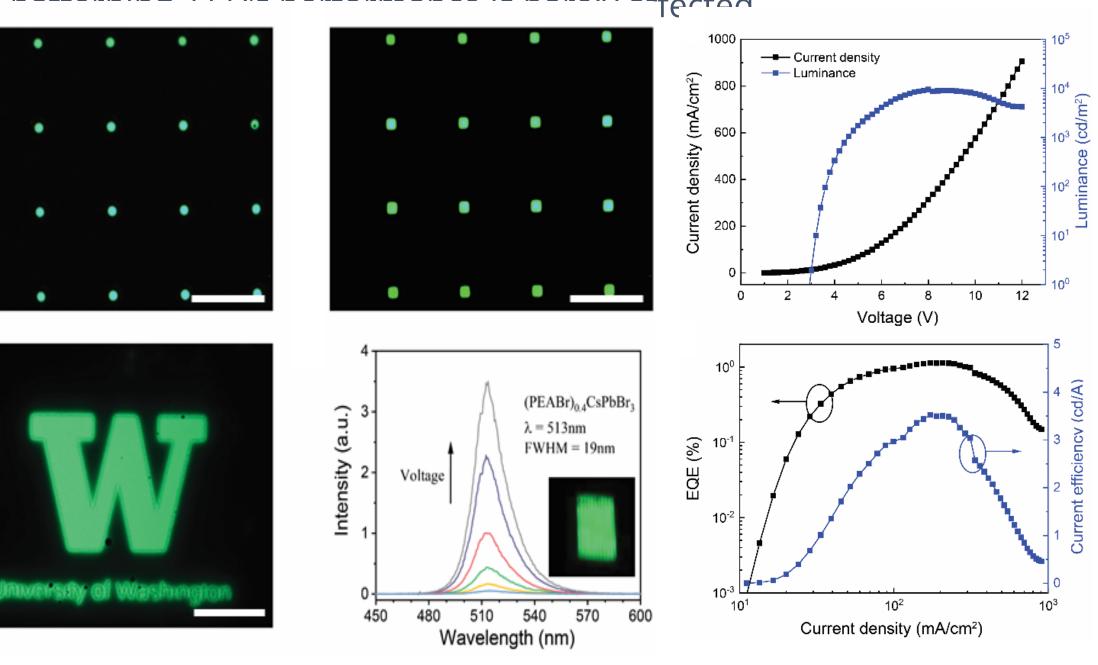
- By repeating this method, multi-color patterns can be obtained.
- The intermediary layer also works as a protective layer, which will prevent perovskites from the moisture and polar solvent during fabrication.



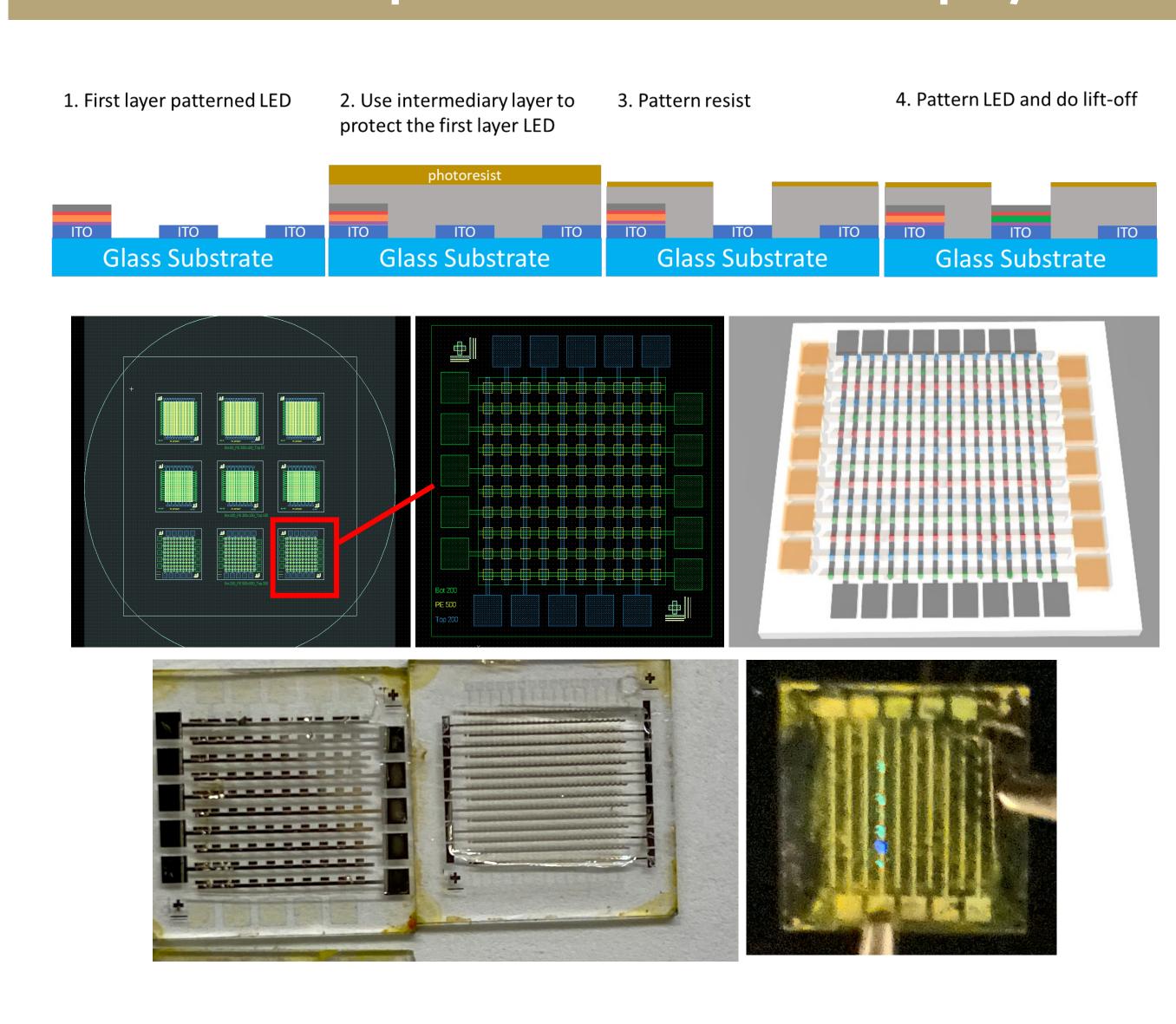
Patterned perovskite LEDs

- Instead of only patterning perovskites, we can directly fabricate patterned perovskite LEDs.
- For a perovskite LED, its HTL, ETL and electrode can be patterned at the same time.

 After the matter is a LED/a matternance is bounded of the patterned at the same time.



Towards perovskite micro-LED display



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